Electronic Patent Application Fee Transmittal							
Application Number:	10	10518371					
Filing Date:	28	-Dec-2004					
Title of Invention:		Plasma chemical vapor deposition method and plasma chemical vapor deposition device					
First Named Inventor/Applicant Name:	Hir	Hiroshi Mashima					
Filer:	Ma	Marvin Jay Spivak/Tiffany Tillett					
Attorney Docket Number:	263787US2PCT						
Filed as Large Entity							
U.S. National Stage under 35 USC 371 Filing	Fee	s					
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:							
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							
Extension-of-Time:							
Extension - 1 month with \$0 paid		1251	1	130	130		

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
	Total in USD (\$)			130